

2026 SID Honors and Awards



Presented
May 2026

Foreword

Through our Honors and Awards Program, SID recognizes and celebrates those individuals whose advances have contributed to the display industry and who have supported the society and the community with their effort. These contributions span specific technological and scientific advances, outstanding educational achievements, and notable service to the industry and SID as a society.

Deciding the most deserving recipients for the various awards is no easy task. Each year, the Honors and Awards Committee selects and recommends recipients to the board of directors for approval. The committee worked hard to maintain the highest ethical and technical standards in selecting the individuals being honored today. On behalf of the society, I extend my deepest gratitude to my colleagues on the committee for their service and the dedication and professionalism they have shown throughout this selection process.

Finally, let me offer my warmest congratulations to all this year's award recipients. It is an honor for the society to present these awards to you and to both recognize your achievements and inspire the next generation of award winners in the future.

Qun (Frank) Yan
SID President

Honors and Awards Committee

Toshiaki Arai

Jason Hartlove

Takahiro Ishinabe

HS Kwok

Baoping Wang

Paul Drzaic (chair)

Yongtaek Hong

In Byeong Kang

Arokia Nathan

Qiong-Hua Wang

Michael Hack

Yi-Pai Huang

Yong-Seog Kim

Robert Visser

Deng-ke Yang

2026 Honors and Awards

Karl Ferdinand Braun Prize for Technological Impact

Hyun Chul Choi

David Sarnoff Industrial Achievement Award

Frank Ko

**Jan Rajchman Prize for
Science and Technology in Displays**

Changhee Lee

Peter Brody Prize for Early Career Achievement

Linghui Rao

**Slottow-Owaki Prize for
Education and Training in Displays**

Yukiharu Uraoka

Otto Schade Prize for Image Quality in Displays

Michael Abrash

Lawrence Tannas Award for Volunteer Service

Thomas Fiske

Fellows of the SID

Ion Bitu

Yang Joon-Young

Yu-Chieh Lin

Abhishek Srivastava

Chung Yi

Shengdong Zhang

Special Recognition Awards

Lian Duan

Hidekazu Hatanaka

Zhiqiang Liu

Kwonshik Park

Byung Duk Yang

KARL FERDINAND BRAUN PRIZE FOR TECHNOLOGICAL IMPACT

The Karl Ferdinand Braun Prize recognizes outstanding technical achievement and substantial impact on the display industry. The Braun Prize is SID's most prestigious individual award, honoring those people who have pioneered the technologies underpinning commercial displays.



Hyun Chul Choi

For leadership in developing and commercializing tandem OLED displays as well as IPS LCD technology, enabling the success of many products in large-screen TVs, high-performance IT products, and automotive displays.

Hyun Chul Choi is executive vice president and head of the SC Business Unit at LG Display. With more than three decades of experience in display research and development, he has played a leading role in advancing OLED and LCD technologies from laboratory innovation to large-scale manufacturing. Through pioneering tandem OLED architectures that significantly enhanced device efficiency, lifetime, and reliability, Choi was instrumental in establishing OLED as a mainstream display technology. His work laid the technological foundation for premium OLED TVs and further extended OLED adoption into IT and automotive applications. Earlier in his career, Choi played a pivotal role in the commercialization of in-plane switching (IPS) technology for large TVs, high-end IT, and mobile products, establishing IPS as the standard technology for high-performance LCDs. In recognition of his sustained technological leadership and industrial impact, he was elected an SID Fellow and has received additional major honors, including the SID Special Recognition Award. He is also a member of the National Academy of Engineering of Korea.

DAVID SARNOFF INDUSTRIAL ACHIEVEMENT AWARD

The David Sarnoff Industrial Achievement Award is conferred for major impact and business leadership in the electronic display industry.



Frank Ko

For exceptional leadership advancing e-Paper to global prominence at E Ink and pioneering microLED at AUO, while strengthening Taiwan’s display industry through innovation, green manufacturing, and international collaboration.

As president and group COO of AUO Corp., **Frank Ko** leads the company’s operational integration across display, mobility, and vertical solution sectors. With more than two decades of industry expertise, he has been instrumental in AUO’s evolution, overseeing critical functions from R&D and manufacturing to global sales. Ko is recognized for his ability to synthesize complex operational resources into cohesive, innovative business strategies. He previously served as chairman and CEO of E Ink Holdings, Inc., where he was a key architect in expanding the e-Paper ecosystem. Since returning to AUO in 2019, he has focused on fostering a “global-first” operational mindset, driving technological breakthroughs that strengthen AUO’s market position. As a well-rounded management professional, Dr. Ko has dedicated his career to pushing the boundaries of display technology and creating high-value, sustainable solutions for a connected world.

JAN RAJCHMAN PRIZE FOR SCIENCE AND TECHNOLOGY IN DISPLAYS

The Jan Rajchman Prize is awarded for outstanding scientific or technical contributions to electronic display technology.



Changhee Lee

For many pioneering contributions to novel displays and components using OLEDs, quantum dots, and nano-LEDs.

Changhee Lee is CTO and EVP of Samsung Display Co. He developed the first cadmium-free QD-LED (EL-QD) devices and elucidated their degradation mechanisms. His team developed all-inkjet-printed Cd-free QD-LED displays (showcased at Display Week 2023–2025) by overcoming challenges such as interlayer mixing and film defects. His team also realized a breakthrough in the size-dependent efficiency reduction problem of blue InGaN nano-LEDs, achieving a world-record EQE of 20.2%. Furthermore, he redefined the display as a bidirectional interface by integrating organic photodiodes directly into OLED panels. This sensor OLED created a multifunctional bio-interactive platform capable of multi-point fingerprint sensing and cardiovascular diagnostics. Lee is an SID Fellow and a member of the Korean Academy of Science and the Technology and National Academy of Engineering of Korea. He received his PhD in physics from the University of California at Santa Barbara in 1994.

PETER BRODY PRIZE FOR EARLY CAREER ACHIEVEMENT

The Peter Brody Prize is awarded to researchers and engineers under age 40 who have made major technical or scientific contributions to electronic display technology.



Linghui Rao

For exceptional contributions to the research and development of ultra-high pixel density liquid-crystal displays for VR applications.

Linghui Rao is a recognized technical leader in advanced display and optical technologies for VR/MR systems. As the director of display engineering at Meta, she drives the development of ultra-high-resolution display systems. Her pioneering contributions have pushed the boundaries of high-PPI display technology and continue to shape next-generation architectures. Before joining Meta, Rao was an engineering lead at Microsoft, where she led display and touch module innovations for the Surface product portfolio. She earned her PhD from the College of Optics and Photonics (CREOL) at the University of Central Florida. A member of SID since 2007, she joined the SID-LCT Subcommittee in 2016 and currently serves as co-chair. Rao holds more than 30 US patents and has authored more than 50 publications, including many invited talks and distinguished papers. She is the recipient of the 2014 ILCS Glenn Brown Prize.

SLOTTOW-OWAKI PRIZE FOR EDUCATION AND TRAINING IN DISPLAYS

The Slottow–Owaki Prize is awarded for outstanding contributions to the education and training of students, and/or professionals, in the field of electronic displays.



Yukiharu Uraoka

For exceptional dedication to educating and mentoring future leaders in electronic displays and semiconductors, and for fostering global talent development through international collaboration and academic leadership.

Yukiharu Uraoka is a professor at the Nara Institute of Science and Technology (NAIST) and a leading expert in semiconductor engineering and electronic displays. A dedicated educator, he has supervised 78 PhD students from academia and industry worldwide. After receiving his BS, MS, and PhD from Toyohashi University of Technology, he spent 14 years at Panasonic, contributing to the development and commercialization of LTPS-TFT displays and advanced reliability evaluation methods. He later joined NAIST, where he has served since 2009, most recently as professor and director of the Material Research Platform Center. Uraoka is internationally recognized for his work in oxide semiconductors, particularly IGZO TFT reliability, with technologies transferred to numerous companies. He has authored more than 370 journal papers and more than 200 conference papers. He holds dozens of patents. Uraoka is an IEEE Fellow and a recipient of multiple awards. He actively leads major international conferences and editorial activities, contributing to global talent development in semiconductors and displays.

OTTO SCHADE PRIZE FOR IMAGE QUALITY IN DISPLAYS

The Otto Schade Prize is awarded for outstanding scientific or technical achievement in the image quality of electronic displays. This prize recognizes vision scientists, human factor engineers, and those engineers whose efforts have led to major improvements in the visual quality of electronic displays.



Michael Abrash

For defining the foundational characteristics of modern AR/VR systems and pioneering the technical innovations in image quality that enabled high-fidelity immersive headset experiences.

Michael Abrash is the chief scientist at Meta Reality Labs, a research laboratory that brings together a world-class R&D team of scientists, developers, and engineers to build the future of connection via virtual reality, augmented reality, and wearables. He served as graphics lead for the first two versions of Windows NT, teamed with John Carmack on Quake, worked on the first two versions of Microsoft's Xbox, and helped develop virtual reality at Valve. Abrash was the author of the *Dr. Dobb's Journal* "Rambling in Realtime" and "Graphics Programming" columns, as well as of performance and graphics programming columns in *PC Techniques* and *Programmer's Journal*. He is the author of several books, including *The Zen of Graphics Programming* and *Michael Abrash's Graphic Programming Black Book*.

LAWRENCE TANNAS AWARD FOR VOLUNTEER SERVICE

The Lawrence Tannas Award is conferred for exceptional and sustained service to SID.



Thomas Fiske

For more than three decades of service to SID, including work within Display Week leadership, guest editorship for JSID and ID magazine, and stewardship of the ICDM as definitions and standards chair.

Thomas Fiske is a 35-year veteran of the display industry, specializing in display technology, image quality, and optical metrology. He has worked with a number of display technologies and applications at a variety of companies, including Xerox PARC, dpiX, Rockwell Collins, Qualcomm, Microsoft, and Intuitive Surgical, where he is currently senior manager for displays and optics.

A constant theme across his career has been his involvement with SID. He has served at SID in several capacities: chair of SID's Definition and Standards Committee since 2012, a member of the SID Symposium Program Committee since 1995, program chair for the Display Week Symposium in 2008, general chair of Display Week in 2010, and a reporter on display measurement and image quality topics at Display Week for *Information Display* magazine since 2015. He counts as his most significant contribution to SID his leadership role on the International Committee for Display Metrology, which makes industry-leading contributions to display measurement methods and standards.

SID FELLOWS

The membership grade of Fellow is awarded to an SID member who has made outstanding and widely recognized engineering or scientific contributions to the display field. The number of SID Fellow awards each year is limited by policy set by the SID Board of Directors.

Ion Bita

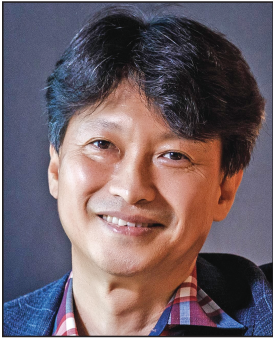
For sustained contributions to the display community developing multiple innovative display technologies for reflective MEMS, microLED, and OLED displays and new consumer electronic display products.



For the past 20 years, ***Ion Bita*** has helped develop and launch multiple innovative display technologies, including reflective MEMS displays, light-guides with integrated touch sensors, microLED displays, and innovative mobile OLED displays, with many of them successfully commercialized in new products across smartwatch, smartphone, foldable phone, and tablet/e-reader categories. He currently leads display architecture and new technology introduction for Pixel Hardware in Google's Devices and Services division. Previously he worked at Apple and Qualcomm in entrepreneurial divisions created from startup acquisitions. Bita has contributed to ~100 patent filings, multiple publications, and book chapters, and has also co-edited the book *Flat Panel Display Manufacturing* (Wiley 2018). He was the technical program chair for SID's 2025 International Symposium (Display Week), past chair of the SID Display Manufacturing Committee, and associate editor of the *Journal of the Society for Information Display*. Bita completed his studies at the Massachusetts Institute of Technology, receiving BSc degrees in chemical engineering and chemistry, and a PhD in materials science & engineering with research in nanofabrication, optoelectronics, and photonics.

Yang Joon-Young

For developing innovative display technologies and leading their implementation in product design and production through global industry partnerships.



Yang Joon-Young's research interests center on display technology with a particular focus on TFT devices, fabrication processes, and advanced panel design. After joining LG Group in 1995, he played a leading role in the development of ultra-high-resolution display panels and next-generation display technologies, including rollable, transparent, and stretchable displays. He currently serves as head of the Advanced Technology R&D Center at LG Display, where he promotes innovation in display science and engineering. His technical achievements have been recognized by the Society for Information Display (SID), from which he received the Special Recognition Award (SRA) in 2024. In 2026, he was elected an associate member of the National Academy of Engineering of Korea (NAEK) in recognition of his distinguished contributions to academia and industry. Joon-Young earned his bachelor's, master's, and doctoral degrees in engineering from Korea University.

Yu-Chieh Lin

For pivotal contributions to the development and commercialization of microLED displays and sensor technologies, and for leadership that delivered world-first milestones across diverse applications.



Yu-Chieh (Jennifer) Lin is vice president of the Innovation Research & Development Group at AUO Corp. She has played a pivotal role in developing microLED display technology, overseeing the commercialization of groundbreaking products such as the world's first microLED smartwatch and automotive display. She led the development of the first TFT optical fingerprint sensor, advancing applications in biometrics and medical diagnostics. Under her leadership, AUO introduced transparent, flexible, rollable, foldable, and stretchable microLED displays, setting new industry standards for quality and user experience. Her achievements have been recognized with numerous honors, including the CES Innovation Award and the People's Choice Award at Display Week. Through her commitment to global collaboration and visionary leadership, Lin continues to strengthen AUO's position at the forefront of next-generation display technologies, inspiring ongoing innovation in the field. She holds a master's degree in physics from National Central University.

Abhishek Srivastava

For sustained leadership in optical materials innovation, pioneering advances in ferroelectric liquid crystals, LC alignment technologies, and quantum-rod performance for visual display systems.



Abhishek Srivastava is an associate professor and associate director of the Centre for Display Research in the Department of Electronic & Computer Engineering at the Hong Kong University of Science and Technology. His current research interests include photoalignment technology, nanomaterials, and fast-response liquid crystals for advanced displays and photonic devices. In 2014, he received the ILCS Early-Career Award, also known as the Michi Nakata Prize, for his outstanding contributions to the field of ferroelectric liquid crystals and photoalignment. In 2018, he received the I-Zone Best Prototype award at SID's Display Week for his ferroelectric liquid-crystal displays. In the same year, he earned the LG Bronze Award from the Korean Information Display Society for a newly developed quantum-rod enhancement film. To date, he has published 260 research papers and holds 50 patents/patent applications. He is the editor-in-chief of the *Journal of the Society for Information Display*. He is also a senior member of the Society for Information Display (SID) and a member of IEEE, SPIE, and the International Liquid Crystals Society. He received his PhD in 2009 from the University of Lucknow, India.

Chung Yi

For pioneering the world's first foldable OLED displays and multiple other advances in OLED display technology, and for leadership in advancing display ecosystems toward energy efficiency and environmental sustainability.



Chung Yi, president and CEO of Samsung Display, is a visionary leader who has driven transformative innovations in display technology for more than three decades. He played a pivotal role in developing and commercializing groundbreaking technologies such as the world's first touch sensor-integrated flexible OLED, a full-screen OLED with an under-display camera, and foldable OLED displays. Under his leadership, Samsung Display successfully mass-produced ultra-low-power polarizer-free OLEDs, significantly enhancing energy efficiency and sustainability. He has spearheaded advancements across mobile, IT, automotive, and VR applications, securing the world's highest market share in smartphone OLED panels. Yi holds a PhD in chemical engineering from POSTECH and is deeply committed to advancing the industry, currently serving as chairman of the Korea Display Industry Association (KDIA) and president of the Korean Information Display Society (KIDS). In 2024, he received an SID Special Recognition Award in honor of his outstanding contributions to the display industry. His strategic vision and technical expertise continue to shape the future of displays, reinforcing Samsung Display's position at the forefront of global innovation.

Shengdong Zhang

For outstanding contributions to TFT-integrated circuit development for advanced displays and flexible electronics, and for pioneering innovations in metal-oxide TFT technologies and quantum-dot LED displays.



Shengdong Zhang's research interests encompass thin-film transistor (TFT) device structures, physics, and materials, as well as TFT integrated circuits for display electronics and photosensors. He received his BS and MS degrees in electrical engineering from Southeast University, China, and his PhD in microelectronics from Peking University, China. After working for more than 10 years at the Nanjing Electron Devices Institute and a few years at the Hong Kong University of Science and Technology, he joined the School of Electronics Engineering and Computer Science at Peking University, later moving to the School of Electronic and Computer Engineering at Peking

University Shenzhen. He serves as an editor of IEEE *Electron Device Letters*, overseeing manuscripts on TFTs, displays, and sensors, and also as an associate editor of the *Journal of Information Display*.

SPECIAL RECOGNITION AWARDS

Special Recognition Awards are conferred for distinguished and valued contributions to the field of electronic displays. Unlike other SID individual awards, SID membership is not a prerequisite for a Special Recognition Award.

Lian Duan

For outstanding contributions to OLED materials and device technology, and for leadership in international collaborations that advanced OLED industrialization.

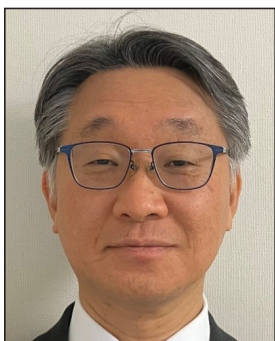


After working at the R&D Center of Samsung SDI for two years, **Lian Duan** joined the department of chemistry at Tsinghua University. His research interests center on materials and devices for OLED displays, with his recent work primarily focused on narrowband emitters and sensitized fluorescent devices for wide-color-gamut displays. He has authored and co-authored more than 300 SCI-indexed papers, with more than 25,000 citations. He has over 300 patents filed with approximately 250 issued. Duan has been an editor of *Organic Electronics* since 2019. He serves as deputy chair of the OLED committee of SID's Beijing Chapter. He received his BS and PhD from

Tsinghua University, both in chemistry.

Hidekazu Hatanaka

For breakthrough contributions in green laser diode development and speckle reduction that enabled commercial RGB laser projection systems for premium cinema applications.



Hidekazu Hatanaka, a research administrator for the RIKEN Center for Advanced Photonics (RAP) in Japan, focuses on display and laser technologies, with particular emphasis on laser-based display systems and light-source innovation. His work bridges fundamental research, industrial innovation, and international scientific collaboration across disciplines. Hatanaka received his BS, MS, and PhD in electrical engineering from Keio University and later earned an MBA from Bond University, Australia. His early research career included a postdoctoral appointment at Los Alamos National Laboratory. He then contributed to the development of advanced laser products at

NEC Corp. and conducted display research and development at the Samsung Advanced Institute of Technology. At USHIO, Inc., he played a key role in the commercialization of light sources for laser projectors. Hatanaka currently serves as a member of the technical program committee for SID's International Symposium (Display Week) and is a senior member of the Society for Information Display. He also serves as a director of the Laser Society of Japan.

Zhiqiang Liu

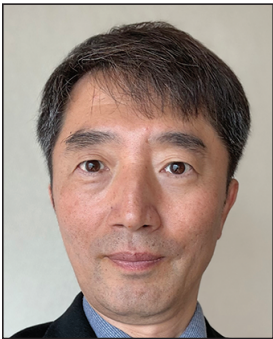
For pioneering achievements in advanced display technologies and outstanding leadership in transforming innovations into large-scale production through global industry collaboration.



Zhiqiang Liu is SVP and CTO of BOE Technology Group, and a core member of its executive committee. With rich innovative and management expertise in semiconductor displays, he has held pivotal leadership roles across BOE’s key subsidiaries—serving as chairman of Hefei, Ordos, Hebei and Qingdao BOE optoelectronic units, and general manager of Nanjing BOE Display Technology. With a strong engineering background and strategic thinking, Liu has established innovations in LCD, OLED, micro/miniLED, AR/VR, and next-generation interactive displays, leading BOE from a technology follower to a global industry leader. Guided by the principle of “technology-driven value creation,” he has promoted integrated innovation across materials, devices, systems, and ecosystems. His contributions to the industry have been widely recognized, with honors including: the First Prize of Beijing Municipal Science and Technology Progress Award, Hefei High-Level Talent, Anhui Provincial Government Quality Award, Leader of Hefei’s “228” Industrial Innovation Team, and Hefei Outstanding Entrepreneur.

Kwonshik Park

For pioneering contributions to gate driver-in-panel (GIP) technology across mobile and large-screen displays, and for commercializing advanced oxide TFT technology in world-first OLED products.



Kwonshik Park is a distinguished expert in display technology with more than 25 years of leadership in the semiconductor and display industries. He currently serves as an advisor at LG Display, following a successful tenure as head of the Foundation Technology Laboratory. Park is widely recognized for his pioneering contributions to oxide TFT technology and gate driver-in-panel (GIP) technology. He has played a decisive role in the development and mass production of numerous world-first LCD and OLED product lines, many of which have set global industry standards. His leadership in R&D fab operations and new process integration has been instrumental in bridging cutting-edge laboratory research with large-scale manufacturing excellence. He holds a BS, MS, and PhD in materials science and engineering from Seoul National University and KAIST. An active member of the SID AMD technical program subcommittee since 2017, his technical excellence has been honored with the Prime Minister’s Citation (2023) and the President of KIDS Award (2020).

Byung Duk Yang

For distinguished contributions to mobile display engineering through pioneering innovations, industry standards advancement, and cross-industry leadership in system integration.



Byung Duk Yang is executive vice president and head of the display group at Samsung Electronics, where he has led the advancement of mobile display technologies across materials, panel architecture, mechanics, driving electronics, and system integration since joining the company in 2004. Yang pioneered the commercialization of foldable displays, delivering industry firsts including ultra-thin glass cover windows, under-display camera technology, and EMR pen input, which collectively established the foundation for today's industry-standard foldable display architectures for durability and reliability. He spearheaded the Video Hybrid Mode, which became part of the

MIPI DSI standard, through cross-industry collaboration, enabling substantially improved power efficiency and user experience. He also originated and brought to fruition the world's first smartphone-optimized privacy display, creating an entirely new class of display architecture that enables built-in, pixel-level privacy within the panel itself. He holds a PhD in ceramic engineering from Yonsei University.

SID Honors and Awards

KARL FERDINAND BRAUN PRIZE FOR TECHNOLOGICAL IMPACT

The Karl Ferdinand Braun award is awarded for outstanding technical achievement and substantial impact on the display industry. The Braun award is SID's most prestigious individual award, honoring those people who have pioneered the technologies underpinning commercial displays. Each recipient of the Braun Prize receives a stipend of \$5,000 sponsored by SID, a medallion, and a bound certificate.

1987	T. Peter Brody	2006	Christopher N. King
1988	Toshio Inoguchi	2008	Richard Williams
1989	Norman F. Fyler	2010	Frederic Kahn
1989	Harold B. Law	2011	Rudolf Eidenschink
1989	Edward G. Ramberg	2012	Jun Souk
1989	Alfred C. Schroeder	2013	Isamu Akasaki
1990	Akio Ohkoshi	2014	Katsumi Kondo
1991	Kentaro Kiyozumi	2015	Junji Kido
1991	Tadashi Nakamura	2016	Ho Kyoon Chung
1992	Martin Schadt	2017	Hiroyuki Ohshima
1993	William E. Glenn	2018	Hidefumi Yoshida
1993	William E. Good	2019	Amal Ghosh
1993	Thomas T. True	2020	Julie Brown
1995	Eiichi Yamazaki	2021	Sungchul Kim
1996	George W. Gray	2022	Wei Chen
1997	Isamu Washizuka	2022	John Zhong
1998	Cyril Hilsun	2023	Hideo Hosono
1999	Larry J. Hornbeck	2023	Toshio Kamiya
2000	Larry F. Weber	2023	Kenji Nomura
2003	Tsutae Shinoda	2024	Ching Tang
2004	Shuji Nakamura	2024	Steven Van Slyke
2005	William P. Bleha	2025	Xiaolin Yan

DAVID SARNOFF INDUSTRIAL ACHIEVEMENT AWARD

The David Sarnoff Industrial Achievement Award is conferred for major impact and business leadership in the electronic display industry. Each recipient of the Sarnoff Award receives a stipend of \$5,000 sponsored by SID, a medallion, and a bound certificate.

2018	Sang Wan Lee	2022	SangDeog Yeo
2019	Dongsheng Wang	2023	Jason Hartlove
2020	Paul Peng	2024	Yanshun Chen
2021	Tomson Li Dongsheng	2025	Joo Sun Choi

JAN RAJCHMAN PRIZE FOR SCIENCE AND TECHNOLOGY IN DISPLAYS

The Jan Rajchman Prize is awarded for outstanding scientific or technical contributions to electronic display technology. Each recipient of the Rajchman Prize receives a stipend of \$5,000 sponsored by SID, a medallion, and a bound certificate.

1993	Terry J. Scheffer	2010	Dwight Berreman
1994	Peter G. LeComber	2011	Hideo Hosono
1995	Shunsuke Kobayashi	2012	Tetsuo Tsutsui
1996	Robert Meyer	2013	Marc Baldo
1996	Capp Spindt	2014	Dirk J. Broer
1998	J. William Doane	2015	Shohei Naemura
2001	Ching W. Tang	2016	Seung Hee Lee
2001	Steve Van Slyke	2017	Shui-Chih Alan Lien
2003	Webster E. Howard	2018	Pochi Yeh
2004	Tatsuo Uchida	2019	Hoi-Sing Kwok
2005	Donal Bradley	2020	Paul Alivisatos and Moungi Bawendi
2005	Jeremy H. Burroughes	2021	Karl Leo
2005	Richard Friend	2022	Jin Jang
2006	Stephen R. Forrest	2023	Tsuyoshi Sekitani
2006	Mark E. Thompson	2024	Franky So
2007	Shigeo Mikoshiba	2025	Chihaya Adachi
2008	Shin-Tson Wu		
2009	Peter Raynes		

PETER BRODY PRIZE FOR EARLY CAREER ACHIEVEMENT

The Peter Brody Prize is awarded to researchers and engineers under age 40 who have made major technical or scientific contributions to electronic display technology. Each recipient of the Brody Prize receives a stipend of \$5,000 sponsored by SID, a medallion, and a bound certificate.

2017	Yi-Pai Huang	2022	Keisuke Ide
2018	Seth Coe-Sullivan	2023	Weiran Cao
2019	Hsing-Hung Hsieh	2024	Dongchuan Chen
2020	Zhaojun Liu	2025	Yifan Zhang
2021	Hiromi Minemawari		

SLOTTOW-OWAKI PRIZE FOR EDUCATION AND TRAINING IN DISPLAYS

The Slottow-Owaki Prize is awarded for outstanding contributions to the education and training of students, and/or professionals, in the field of electronic displays. Each recipient of the Slottow-Owaki Prize receives a stipend of \$5,000 sponsored by SID, a medallion, and a bound certificate.

2007	J. William Doane	2016	Shunsuke Kobayashi
2008	Tatsuo Uchida	2017	Deng-Ke Yang
2009	Ernst Lueder	2018	Vladimir Chigrinov
2010	Philip Bos	2019	Chain-Shu Hsu
2011	Shin-Tson Wu	2020	Edward F. Kelley
2012	Lawrence E. Tannas, Jr.	2021	Man Wong
2013	Hoi-Sing Kwok	2022	Hiroyoshi Naito
2014	Han-Ping Shieh	2023	Xiao Wei Sun
2015	Jin Jang	2025	Oh-Kyong Kwon

OTTO SCHADE PRIZE FOR IMAGE QUALITY IN DISPLAYS

The Otto Schade Prize is awarded for outstanding scientific or technical achievement in the image quality of electronic displays. This award recognizes vision scientists, human factor engineers, and those engineers whose efforts have led to major improvements in the visual quality of electronic displays. Each recipient of the Otto Schade Prize receives a stipend of \$5,000 sponsored by SID, a medallion, and a bound certificate.

2006	Curtis R. Carson	2017	Martin S. Banks
2006	Roger Cohen	2020	Yoshifumi Shimodaira
2007	Andrew B. Watson	2021	Mark D. Fairchild
2008	Louis D. Silverstein	2022	Taiichiro Kurita
2010	Eli Peli	2023	Helge Seetzen
2011	Scott Daly	2023	Greg Ward
2012	Adi Abileah	2023	Lorne Whitehead
2014	Candice Brown Elliott	2024	Gordon Wetzstein
2015	Ingrid Heynderickx	2025	Kenichiro Masaoka
2016	Nikhil Balram		

LAWRENCE TANNAS AWARD FOR VOLUNTEER SERVICE

(The SID award for volunteer service was named for Lewis and Beatrice Winner from 1983–2024, and renamed for Lawrence Tannas in 2025).

The Lawrence Tannas Award is conferred for exceptional and sustained service to SID. Each recipient of the Tannas Award receives a stipend of \$5,000 and a plaque.

1983	Bernard J. Lechner	2004	Jay Morreale
1984	Lewis Winner	2006	Aris Silzars
1985	Solomon Sherr	2007	Andras Lakatos
1987	Harold R. Luxenberg	2009	Peter Baron
1988	Irving Reingold	2010	Makoto Maeda
1989	Ifay F. Chang	2012	Webster E. Howard
1990	Koichi Miyaji	2013	Shigeo Mikoshiba
1991	John van Raalte	2014	Jennifer Bach
1992	Masakazu Fukushima	2015	Allan Kmetz
1993	Lawrence E. Tannas, Jr.	2016	Anthony C. Lowe
1994	Howard L. Funk	2017	Kenneth I. Werner
1995	Walter F. Goede	2020	Brian Berkeley
1996	Takehiro Kojima	2021	Larry F. Weber
1998	Chuji Suzuki	2022	Sriram Peruvemba
1999	Philip M. Heyman	2023	Helge Seetzen
2002	Alan Sobel	2024	Stephen Atwood
2003	Shunsuke Kobayashi	2025	Shin-Tson Wu

FRANCES RICE DARNE MEMORIAL AWARD

The Frances Rice Darne Memorial Award, discontinued in 1987, was awarded occasionally to a Society member for an outstanding technical achievement (other than teaching, publication or service) or contribution to the display field. The award was made by the SID Executive Board.

1971	Bernard J. Lechner	1979	Sam H. Kaplan
1973	H. Gene Slottow	1980	James C. Greeson, Jr.
1974	Norman H. Lehrer	1981	Jan A. Rajchman
1975	Harold B. Law	1984	George E. Holz
1976	Cecil E. Land	1984	James A. Ogle
1977	Vernon J. Fowler	1985	Peter Pleshko
1978	Irving Reingold	1986	James L. Ferguson

JOHANN GUTENBERG PRIZE

The Johann Gutenberg Prize was awarded for an outstanding TECHNICAL achievement in, or contribution to, printer technology. The award was made by the Executive Board acting on the recommendation of the Honors and Awards Committee. The award was discontinued in 2008.

1987	Gary K. Starkweather	1998	C. Wayne Jaeger
1988	C. Hellmuth Hertz	1998	Donald Titterington
1989	Shigehisa Nakaya	1999	Dan A. Hays
1990	Albert S. Chow	2000	Seung Ho Baek
1990	Richard H. Darling	2000	Charles DeBoer
1991	Ichiro Endo	2001	Minoru Usui
1991	John L. Vaught	2002	Robert W. G. Hunt
1992	Richard A. Fotland	2004	Masaki Kutsukake
1993	Robert W. Gundlach	2005	Josef Schneider
1994	Akito Iwamoto	2006	Michio Shinozaki
1995	Hiroaki Kotera	2007	Jeffrey J. Folkins

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1963	Ruth M. Davis	1982	John M. Constantine
1963	James H. Howard	1982	Peter D. T. Ngo
1964	Anthony Debons	1983	Yoshifumi Amano
1965	Rudolph L. Kuehn	1983	T. Peter Brody
1966	Edith Bardain	1983	Webster E. Howard
1966	William P. Bethke	1983	Lawrence E. Tannas, Jr.
1966	Carlo P. Crocetti	1984	Thomas L. Credelle
1966	Frances R. Darne	1984	Werner E. Haas
1966	Harold R. Luxenberg	1984	P. Andrew Penz
1966	Petro Vlahos	1985	C. J. Gerritsma
1967	William R. Aiken	1985	Allan R. Kmetz
1967	Sid Deutsch	1986	Tomio Wada
1967	George Dorion	1986	Paul M. Alt
1967	Solomon Sherr	1986	Roger L. Johnson
1968	Fordyce M. Brown	1987	Andras I. Lakatos
1968	Robert C. Carpenter	1987	Shunsuke Kobayashi
1968	Phillip P. Damon	1987	Omesh Sahn
1969	James H. Redman	1988	Dwight W. Berreman
1969	Carl Machover	1988	Akio Sasaki
1969	Louis M. Seeberger	1988	Heiju Uchiike
1970	Leo Beiser	1989	Takehiro Kojima
1970	Nobuo John Koda	1989	Larry F. Weber
1970	Bernard J. Lechner	1989	Zvi Yaniv
1970	Harry H. Poole	1990	Eiji Kaneko
1971	Benjamin Kazan	1990	Christopher N. King
1971	Harold B. Law	1990	Harry L. Snyder
1972	Pierce W. Siglin	1991	Masami Yoshiyama
1973	Irving Reingold	1992	Walter F. Goede
1974	Vernon J. Fowler	1992	Fang-Chen Luo
1974	Charles P. Halsted	1992	Iwao Ohishi
1974	Edwin H. Hiborn	1992	Martin Schadt
1974	George Holz	1993	Peter G.J. Barten
1974	Albert Loshin	1993	Makoto Ikegaki
1975	Lucien M. Biberman	1993	Chuji Suzuki
1975	William E. Good	1994	Masakazu Fukushima
1975	H. Gene Slottow	1994	Edward P. Raynes
1976	Sanai Mito	1994	Tatsuo Uchida
1976	Dalton Pritchard	1995	Hsing-Yao Chen
1976	Gerald K. Slocum	1995	Hiroo Hori
1977	Thomas C. Maloney	1995	Shigeo Mikoshiba
1977	Koichi Miyaji	1996	Carlo Infante
1977	William H. Ninke	1996	Hideaki Kawakami
1977	John A. van Raalte	1966	Alan G. Knapp
1978	Ifay F. Chang	1996	Chizuka Tani
1978	Gentaro Miyazaki	1997	Günter Baur
1978	Peter Pleshko	1997	James Fergason
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1980	Cecil E. Land	1997	Eiichi Yamazaki
1980	Masanobu Wada	1998	Fumiaki Funada
1981	Frederic J. Kahn	1998	William Glenn
1981	Elliott Schlam	1998	Ernst Lüeder
1981	Alan Sobel	1998	Shinji Morozumi
1982	Jay J. Brandinger	1998	P. Neil Yocum

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1999	Shoichi Matsumoto	2009	Sang Soo Kim
1999	Terry J. Scheffer	2009	Jun Souk
1999	Tsutae Shinoda	2009	Sashiro Uemura
2000	J. William Doane	2009	John Zhong
2000	Setsuo Kaneko	2010	Wei Chen
2000	Hiroyuki Ohshima	2010	Edward F. Kelly
2000	Seyno A. Sluyterman	2010	Haruhiko Okumura
2001	Shoji Shirai	2010	Roger Stewart
2001	Takeo Sugiura	2010	Andrew Watson
2001	Shosaku Tanaka	2011	Julie J. Brown
2001	Shin-Tson Wu	2011	In-Jae Chung
2001	Kei-Hsiung Yang	2011	Yoichi Sato
2002	Philip J. Bos	2011	Sung Tae Shin
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2002	Ching W. Tang	2012	Ho Kyoong Chung
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2003	I-Wei Wu	2013	Takatoshi Tsujimura
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2004	Arlie Richard Conner	2014	Chihaya Adachi
2004	Katsumi Kondo	2014	Victor Belyaev
2004	Anthony C. Lowe	2014	Janglin Chen
2004	Masataka Matsuura	2014	Yong-Seog Kim
2004	Kouji Suzuki	2014	Taichiro Kurita
2005	Adi Abileah	2015	Anne Chiang
2005	Gregory P. Crawford	2015	Ryuichi Murai
2005	Paul S. Drzaic	2015	Fuji Okumura
2005	Hoi-Sing Kwok	2015	John Wager
2005	Hiroshi Murakami	2015	Hidefumi Yoshida
2005	Han-Ping Shieh	2016	Achintya K. Bhowmik
2006	Chin Hsin (Fred) Chen	2016	Hideo Hosono
2006	Willem den Boer	2016	In Byeong Kang
2006	Jin Jang	2016	Changhee Lee
2006	Tsunehiko Sugawara	2016	Chung-Chih Wu
2006	Steven A. Van Slyke	2017	Toshiaki Arai
2006	Ki-Woong Whang	2017	Hyun Jae Kim
2007	Michael Hack	2017	Sin-Doo Lee
2007	Myung Hwan Oh	2017	Sang-Hee Ko Park
2007	Kenji Okamoto	2017	Qun (Frank) Yan
2007	Kalluri Sarma	2018	Steven Bathiche
2007	Yoshifumi Shimodaira	2018	Mary Lou Jepsen
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2008	Vladimir Chigrinov	2018	Seok-Lyul Lee
2008	Ingrid Heynderickx	2018	Qiong-Hua Wang
2008	Christo Hosokawa	2019	Shihchang (James) Chang
2008	Junji Kido	2019	Yi-Pai Huang
2008	Seung Hee Lee	2019	Poopathy Karthirgamanathan
2008	Richard McCartney	2019	Sungchul Kim
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2020	ByoungHo Lee
2020	Franky So
2020	Michael Weaver
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2022	Arokia Nathan
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2024	Junbiao Peng
2024	Wei Yao
2025	Kyung Cheol Choi
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2005	Tomokazu Shiga	2013	In-Byeong Kang
2005	Deng-Ke Yang	2013	Isao Kawahara
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2006	Joseph M. Jacobson	2013	Hidefumi Yoshida
2006	Yoshikazu Kanazawa	2013	Takehiro Zukawa
2006	Edward F. Kelley	2014	Mark Bradley Spitzer
2006	Jun Souk	2014	Hyun Jae Kim
2006	Hirofumi Wakemoto	2014	Zenichiro Hara
2007	In-Jae Chung	2014	Changhee Lee
2007	Alex Henzen	2015	Toshio Kamiya
2007	Kalil Kälántár	2015	Byeongkoo Kim
2007	Sang Soo Kim	2015	Yasuhiro Koike
2007	Walter Riess	2015	ByoungHo Lee
2007	Takatoshi Tsujimura	2015	Jun Ho Song
2007	John A. Rupp	2015	Ahihiro Tagaya
2007	Koichi Sakita	2015	Shunpei Yamazaki
2007	Marko M. G. Slusarczuk	2016	Jongseo Lee
2008	Kimio Amemiya	2016	Chang Ho Oh
2008	Alan Jacobsen	2016	Tetsuo Urabe
2008	Sungkyoo Lim	2016	Robert J. Visser
2008	Hiroyuki Mori	2016	Emi Yamamoto
2008	Kiyoshi Yoneda	2017	Masaki Hasegawa
2009	Byung-Chul Ahn	2017	Jang Hyuk (Jeremy) Kwon

2017	Raymond Kwong
2017	Kenichiro Masaoka
2018	Jae-Hoon Kim
2018	Hisahiro Sasabe
2018	Yasushi Tomioka and Noboru Kunimatsu
2018	Katsuhide Uchino
2019	Chiwoo Kim
2019	Jinoh Kwag
2019	Seung-Woo Lee
2019	Xiaogang Peng
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2020	Takuji Hatakeyama
2020	Yun-Li Li
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2023	Soo Young Choi
2023	Gunther Haas
2023	Yue Kuo
2023	Cheng-Chung Lee
2023	Joohyung Lee
2023	Bo-Ru (Paul) Yang
2024	Chris Bower
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2024	Haijun Qiu
2024	Joon Young Yang
2024	Chung Yi
2025	Dieter Haas and Yusin Lin
2025	John Hamer
2025	Jong Hyuk Lee
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